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Surface modification of ZnMgAl-coated steel by dielectric-barrier discharge plasma†

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In this study, ZnMgAl alloy coated steel sheets were exposed to a dielectric-barrier discharge plasma with different gas mixtures (Ar, Ar + 5% O₂, Ar + 5% H₂O). Five different plasma-induced processes were identified at the surface: (i) etching of aliphatic carbon groups, (ii) conversion of absorbed carboxylates to carbonates, (iii) field-induced migration of Zn and Mg towards the surface, (iv) increased oxide layer thickness, and (v) homogenization of the surface potential of the originally very heterogeneous alloy. The relative contribution of each process depended on the specific gas mixture. Peel-test studies showed that all atmospheric-pressure plasma treatments improved the adhesive properties of the alloy coating for two different adhesives (acrylate and epoxy amine). The highest improvement was associated to the case of Ar + 5% H₂O gas mixture, where all described surface processes took place to a high degree.

1. Introduction

Hot-dip galvanised steel is widely used nowadays due to its corrosion protection properties in the automotive and building industries. The protective ZnO coating formed at the surface can be modified into a ZnMgAl alloy by the addition of magnesium and aluminium to the zinc bath. The ZnMgAl coating shows increased corrosion protection even at thinner coating thicknesses.^{1,2} These Zn alloy coatings have attracted a lot of attention in the field of lightweight constructions, although until now the research has been mostly oriented to corrosion studies.^{1–4} However, these alloys must also demonstrate their suitability for adhesion-related processes, which play an important role when it is necessary to apply additional coatings (painting), or adhesives (when joining in multi-material structures, for example). Within this context, it is of great interest to investigate surface treatments that permit a tuning of the surface properties of the alloy to specific applications.

Low-pressure plasma surface treatments have been successfully employed in order to increase the wettability and absorbability of polymer films or to improve the adhesion of polymer/metal joins.^{5–8} In most of the existing studies, however, the focus has been on the plasma treatment of the polymer, and little is known about the influence of plasma-treating the alloy-coated metal surfaces.^{9–12} In one of the few existing studies, Pohl *et al.* investigated the influence of both reducing and oxidizing low-pressure plasmas on ZnMgAl coatings.¹⁰ They found that all

plasma treatments removed carbon contaminations from the surface and change the top oxide layer thickness. The plasma treatments were also seen to improve the ordering and stability of phosphonic acid self-assembled monolayers for further functionalisation of the surface. Giza *et al.* showed that a reducing low-pressure plasma treatment of ZnMg₂ surfaces affected the band gap as well when using a mixture of Ar/H₂ as the working gas.⁹ The reducing plasma led to the formation of a polymer/oxide/metal interface highly stable against corrosion.

Even though low-pressure plasma treatments seem to be beneficial, the vacuum-based technology needs makes these treatments cost-intensive and limited in the number of pieces that can be treated simultaneously. Atmospheric-pressure plasma treatments, on the other hand, have the potential to be applied in in-line processes as cost efficient and non-polluting technology. In this context, dielectric-barrier discharges (DBD) have shown the advantage of treating large areas homogeneously. However, it is not fully clear how Zn-based alloy coatings respond to such DBD-treatments.

The aim of this work is to investigate the effect of DBD-plasma treatments on ZnMgAl-alloys. One of the goals is to determine the nature of the surface modifications to the ZnMgAl-alloy as a function of the plasma gas composition (pure Ar, Ar/O₂ and Ar/H₂O). The other is to evaluate the influence of the plasma-induced changes on the adhesion of two different adhesives (epoxy-based and acrylate-based).

2. Experimental part

2.1 Materials

All solvents were analytical reagent grade and were used without further purification. ZnMgAl alloy coated mild steel sheets with a sheet thickness of 1 mm and a coating thickness of about 5

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μm were supplied by ThyssenKrupp Steel. The alloy had a composition in the melt of 98 wt% Zn, 1 wt% Al and 1 wt% Mg. All samples were cleaned consecutively in THF, isopropanol and ethanol, each 10 min in an ultrasonic bath.

2.2 Plasma treatment

The plasma treatment was carried out in a homemade plasma chamber, whose schematic is shown in Fig. 1a (additional information can be found in ref. 9). The advantage of such setup is that the sample can be moved between the plasma treatment position and an analytic position without opening the chamber to air. At the analytic position, discrete polarisation modulated IRRAS (DPM-IRRAS) and Kelvin probe (KP) measurements were performed before and after the plasma treatments.

The DBD plasma electrode consisted of an 18 mm diameter copper disk. The metal disk was capped with a 20 mm diameter Al_2O_3 ceramic disk of 2 cm thickness, which acted as dielectric barrier. The whole electrode was enclosed in a polyether ether ketone (PEEK) container. The sample was grounded and acted as counter electrode. The distance between the sample and the electrode was adjusted to around 1 mm and was kept constant during the experiment.

The gases used had a purity of 99.999% and were purchased from Linde. Three different gas mixtures were compared in this

work. Pure argon, argon with 5% oxygen (Ar/O_2) and argon with 5% water ($\text{Ar}/\text{H}_2\text{O}$). The flows were controlled using mass flow controller (red-y-compact, Vögtlin instruments, Swiss) calibrated to the respective gases. To determine the flow ratio, the oxygen content was measured before the experiments with a lambda probe (BA 4510, Bühler, Germany) and the water content with a humidity sensor (UTF75, Sensor-Tec, Germany). The gas flow ratios were adjusted so that the total flow was always 2 l min^{-1} . All measurements were performed at atmospheric pressure.

A G2000 high voltage generator (Redline, Germany) was used to power the discharge. The voltage was monitored using a high voltage probe (PHV 4002-3, PMK, Germany) and an oscilloscope (HMO 1002, Rohde & Schwarz, Germany). The discharge frequency was 35 kHz, leading to a sinus-like voltage signal. Prior to the measurement the ignition voltage for the given electrode-sample distance was determined for each gas mixture. For each gas mixture, the voltage was set 165 V higher than the ignition voltage thus leading to a discharge applied voltage of 2.9 kV for pure Ar, 3.6 kV for Ar/O_2 and 2.6 kV for $\text{Ar}/\text{H}_2\text{O}$.

Before each plasma treatment, KP and DPM-IRRAS reference measurements were recorded for each sample. During the reference measurements, the chamber was flushed with pure argon (2 l min^{-1}) during 15 minutes. When a gas mixture was used, the second gas was added continuously 5 min before the plasma was ignited. When adding the reactive gas, the flow of pure argon was correspondingly reduced, so that a total gas flow of 2 l min^{-1} was maintained.

The duration of the plasma treatment in all cases was 60 s, after which the samples were directly moved to the analytic position and DPM-IRRAS and KP were measured at the same spot where the respective reference measurement was recorded. During the measurements, the chamber was continuously flushed with pure Ar.

2.2.1 In situ optical emission spectroscopy. The plasma discharge was monitored by optical emission spectroscopy (OES) to investigate the plasma composition and reproducibility. The spectrometer was a USB2G (Plasus GmbH, Germany) with a resolution of 0.4 nm. The light passed through a glass window (cut-off at about 290 nm), was collected by a quartz lens and transmitted to the spectrometer by a glass fibre. The distance to the discharge was approximately 60 mm.

2.2.2 In situ discrete polarization modulated IRRAS studies. The plasma-treated surfaces were characterized *in situ* by means of discrete polarization modulated IRRAS (DPM-IRRAS).¹³

The spectrometer used was a Bruker Vertex 70 (Bruker Optik GmbH, Germany). The IR-beam was focused on the sample with a gold-coated parabolic mirror through a ZnSe window. The beam reflected from the sample exited the chamber through a second ZnSe window and was guided with gold-coated mirrors through a rotatable KRS-5 polariser. The polariser was moved between two settings, one horizontal (p-polarized) and one perpendicular to the plane of incidence (s-polarized). The beam was then focused on a liquid-nitrogen cooled mercury-cadmium-telluride detector (MCT). The sample was investigated under an incidence angle of 75° . The final absorbance

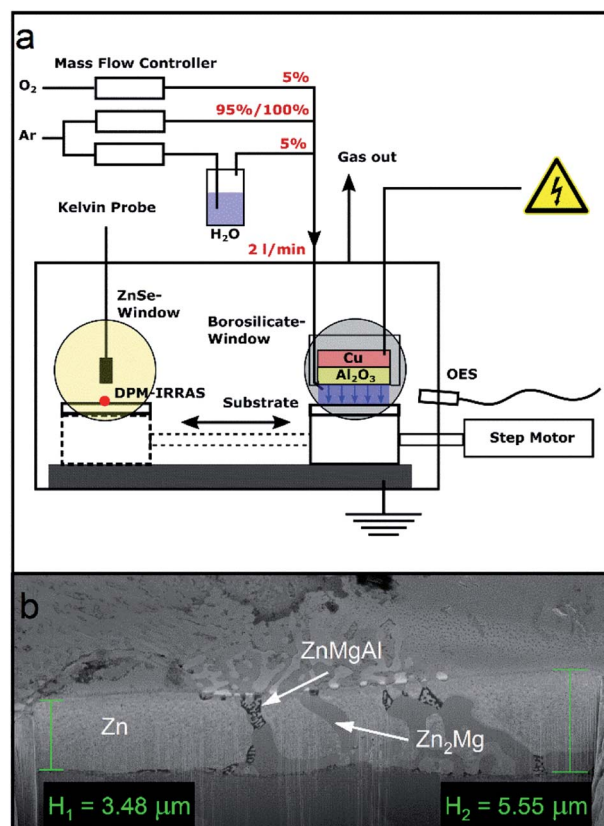


Fig. 1 (a) DBD plasma experimental setup used to treat the ZnMgAl surface and to investigate the plasma induced changes *in situ* with discrete polarized modulated FT-IRRAS and Kelvin probe. (b) SEM cross-section of the native ZnMgAl alloy layer onto steel.



spectrum (A) was calculated by subtracting the averaged absorbance spectrum of s-polarized infrared light (A_s) from the averaged absorbance spectrum of p-polarized infrared light (A_p) according to the following equations:

$$A_p = -\log\left(\frac{I_{1p}}{I_{0p}}\right) \quad (1)$$

$$A_s = -\log\left(\frac{I_{1s}}{I_{0s}}\right) \quad (2)$$

$$A = A_p - A_s \quad (3)$$

I_{1p} and I_{0p} are the intensities after and before plasma treatment for the p-polarized light, while I_{1s} and I_{0s} are the intensities after and before plasma treatment for the s-polarized light. The I_0 and I_1 measurements were performed at the same spot for each sample. Four spectra of 64 scans each were averaged per polarisation direction, with s- and p-polarized light measurements performed alternatively. The spectral resolution was 4 cm^{-1} .

2.2.3 In situ Kelvin probe studies. The plasma-induced changes in the chemistry and semi-conduction properties of the sample were measured *in situ* using a Kelvin probe (KP). The tip was made of CrNi and had a diameter of 2 mm. Potentials were measured as a function of bias voltages at three different distances from the surface, following the measurement principle used by Tahara *et al.*¹⁴ At each distance, the potential was recorded at 40 different bias voltages. Since the measured peak-to-peak distance depends linearly on the bias and is quadratically proportional to the tip-sample distance,¹⁵ the three measurements produced three linear plots with different slopes dependent on the tip-sample distance. The potential at the intersection of the linear plots gives the surface potential. With this method, the error in the determination of the surface potential was between 10–80 mV.

2.3 Ex situ polarization modulated IRRAS

Polarization modulated IRRAS (PM-IRRAS) was performed to study the surface chemistry before the plasma treatment.¹⁶ A ZnSe photo-elastic modulator (PMA50, Bruker Optik GmbH, Germany) modulates an aluminium wire grid at 50 kHz to polarize the light, which is attached to a Vertex V70 spectrometer (Bruker Optik GmbH, Germany). The sample was investigated under an incident angle of 80° . The reflected light was collected using a ZnSe lens onto a liquid-nitrogen cooled MCT detector. 512 single scans were measured with a resolution of 4 cm^{-1} .

2.4 Scanning Kelvin probe force microscopy

Potential scanning Kelvin probe force microscopy (SKPFM) was performed using a MFP-3D-AFM setup (Asylum Research, England). A platinum-coated tip with a force constant of 40 N m^{-1} and a resonance frequency of 350 kHz was used. The scan rate was 0.1 Hz and the resulting images were $70 \times 70 \mu\text{m}^2$ in size.

2.5 Field emission scanning electron microscopy and energy-dispersive X-ray spectroscopy

Field emission scanning electron microscopy (FE-SEM) and energy-dispersive X-ray (EDX) analysis were performed by means of a “NEON 40” FE-SEM (Carl Zeiss SMT AG, Oberkochen, Germany) at an acceleration voltage of 20 kV.

2.6 X-ray photoelectron spectroscopy

Surface chemical characterization was performed by means of X-ray photoelectron spectroscopy (XPS) implemented in an ESCA+ facility (Oxford Instruments, Taunusstein, Germany) at a base pressure $< 3.0 \times 10^{-10}$ mbar using monochromatic Al K α radiation (1486.7 eV). No neutralisation was used. The calibration was performed using the C 1s signal (at 284.6 eV) of adventitious carbon as internal reference. The samples were measured using a take-off angle of 30° with respect to the surface. Surveys were recorded at a pass energy of 100 eV and a step size of 0.2 eV while core level peaks were recorded at a pass energy of 20 eV and a step size of at least 0.1 eV.

2.7 Time-of-flight secondary ion mass spectroscopy

Time-of-flight secondary ion mass spectroscopy (TOF-SIMS) measurements were performed using a TOF-SIMS 5–100 from IONTOF at the Interdisciplinary Centre for Analytics on the Nanoscale (ICAN) of the University of Duisburg-Essen. As primary ion source, a 30 kV Bi⁺ ion gun operated in spectrometry mode at a nominal lateral resolution of 3–10 μm was used. Secondary metal ions were recorded in positive polarity. Interlaced sputtering was carried out using a 2 kV Xe⁺ ion gun as a secondary ion source. A Xe⁺ ion gun rather than an O₂⁺ ion gun was chosen in order to avoid material oxidation throughout depth profiling.

Two different field size settings were used at otherwise identical instrument parameters. Firstly, an analysis field size of $100 \times 100 \mu\text{m}^2$ at a sputter field size of $300 \times 300 \mu\text{m}^2$ was used for fast small area depth profiling through the complete ZnMgAl-coatings. The end of the coating was identified by the appearance and stabilization to a constant value of the Fe⁺ signal (corresponding to the steel substrate). Secondly, an analysis field size of $400 \times 400 \mu\text{m}^2$ at a sputter field size of $1000 \times 1000 \mu\text{m}^2$ was used for large area depth profiling of the surface-near region of the ZnMgAl-films at lower sputtering rates.

2.8 Water contact angle studies

Static water contact angle measurements were carried out with an OCA 15 plus (Dataphysics, Germany), using 5 μL pure water droplets. The drops were evaluated by the Laurentian method.

2.9 90°-peel test under humid conditions

Peel forces were determined under humid conditions by 90°-peel test measurement for two different adhesives: (a) acrylate adhesive tape (Scotch Magic Tape (3 M, Germany)); (b) 2-component epoxy amine adhesive consisting of epoxy resin D.E.R 331 (DOW Chemicals, USA) and amine poly(propylene



glycol)bis(2-aminopropylether) (Sigma Aldrich, Germany). The application of the adhesive was performed immediately after the plasma treatment.

For the two component epoxy amine adhesive, 3.73 g of D.E.R. 331 and 2.26 g poly(propylene glycol)bis(2-aminopropylether) were mixed together and then degassed in vacuum ($<1 \times 10^{-2}$ mbar) for 2 h. To create well-defined film thickness of 150 μm , spacers consisting of three layers of commercial adhesive tape were applied on the samples. The adhesive was applied in dry atmosphere ($<6\%$ r.h.) at room temperature. The coated samples were put on PTFE blocks wrapped with aluminium foil, fixed with clamps and hardened at 120 $^{\circ}\text{C}$ for 75 min in an oven. After the hardening, the PTFE block with the aluminium foil and the spacers were removed from the samples.

Magic Tape was applied in dry atmosphere ($<6\%$ r.h.) by moving a 2 kg rubber roller 8 times over the Magic Tape on the sample.

All samples were exposed after the application of the adhesive for 18 h at 40 $^{\circ}\text{C}$ to humid air (100% r.h.). Subsequently the 90 $^{\circ}$ peel test was performed in a MV-220 Motorized Test Stand (Imada, Japan) at about 85% r.h. The pull-off force was measured with a gauge of type Model ZP-5 (Imada, Japan). The haul-off speed was set to 1 mm s $^{-1}$.

3. Results and discussion

The samples were characterized previously to the plasma treatments with scanning electron microscopy (SEM), energy dispersive X-ray spectroscopy (EDX) and X-ray photoelectron spectroscopy (XPS). The results of these characterizations are shown in the ESI (see Fig. S1 to S3, and Table S1 †).

Cross-sectional SEM images show ZnMgAl-coating thickness between 3.5 and 5 μm (Fig. 1b). The internal structure of ZnMgAl coatings is not homogeneous but it consists of separated regions of Zn, binary Zn₂Mg and ternary ZnMgAl,^{17,18} forming dendrites that can reach sizes between 5–10 μm in diameter.^{17–19}

The composition as determined by EDX is similar to that of other ZnMgAl alloys in literature,^{2,18} showing a high amount of Zn of about 80–90 at% in the bulk material and a spatial-dependent amount of Mg and Al between zero and 20 at% at different Mg/Al ratios. XPS measurements show that the uppermost oxide layer is dominated by aluminium oxide. Mg is also present at the surface but in lower concentrations, while Zn is almost not existent. The enrichment of Al and Mg at the surface is a known aspect of ZnMgAl alloys; however, the enrichment is typically seen to be dominated by Mg, while in our work, Al dominates at the surface-near region.^{18,20}

3.1 OES studies of the bulk plasma composition

Optical emission spectroscopy (OES) was performed on the Ar and Ar/H₂O plasmas in order to identify active species in the plasma and to monitor the stability and reproducibility of the plasma discharge (the Ar/O₂ plasma could not be measured due

to low emission in the visible range). Characteristic OES spectra of the Ar and Ar/H₂O discharges are shown in Fig. 2.

In general, argon plasmas exhibit emission peaks in the region between 690 and 850 nm.²¹ These lines were consistently observed in all experiments, with relative intensity ratios characteristic of each gas mixture. Additional emission lines were observed around 300 and 400 nm. These are assigned to hydroxyl OH radicals (310 nm) and N₂-species (340, 360, 380 nm).²¹ We attribute the appearance of these peaks to residual air in the system. Comparing the OES of pure Ar and Ar/H₂O plasmas, the peak at 310 nm increased by a factor of 4 for the Ar/H₂O mixture, while the Ar lines decreased by a similar factor. The decrease of intensity for the Ar lines in the presence of oxygen and water is attributed to quenching of the emission of Ar by water and oxygen molecules.

3.2 *In situ* IRRAS studies of surface chemical changes during plasma processing

Due to its high surface sensitivity,¹⁶ PM-IRRAS (*ex situ*) was performed to investigate the IR-active species on the untreated samples. DPM-IRRAS (*in situ*) was used to identify the plasma-induced changes in the surface, by performing a direct comparison between the samples before and after the plasma exposure. In this case, the reference was a measurement done on the same spot of each sample immediately before the plasma treatment.

The PM-IRRAS spectra of the untreated, cleaned surfaces (Fig. 3a and b) showed signals corresponding to adsorbed water (3200 cm $^{-1}$), aliphatic carbon groups (2850–2960 cm $^{-1}$), carboxylates (1620 cm $^{-1}$), Al-oxide (920 cm $^{-1}$) and Al-hydroxide (1090 cm $^{-1}$). The peak assignments are summarised in Table 1.

The presence of carbon groups is associated to the existence of so-called adventitious carbon on the sample surface. Since carboxylates are known to contain aliphatic carbon chains and adsorb on oxide-covered metal surfaces, we infer from the

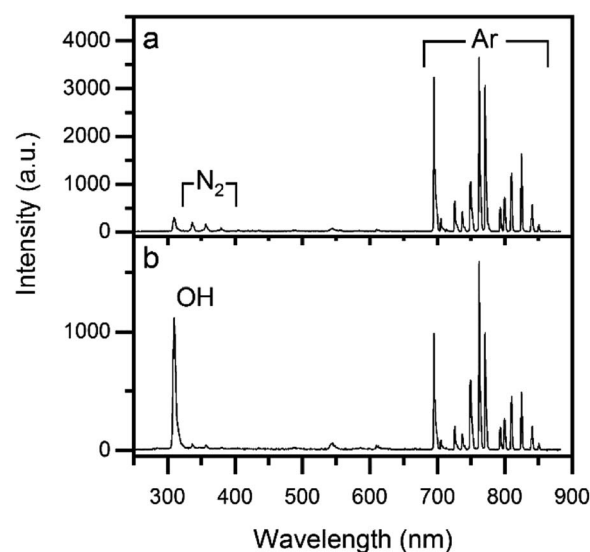


Fig. 2 OES spectra of (a) pure Ar plasma and (b) Ar/H₂O plasma.



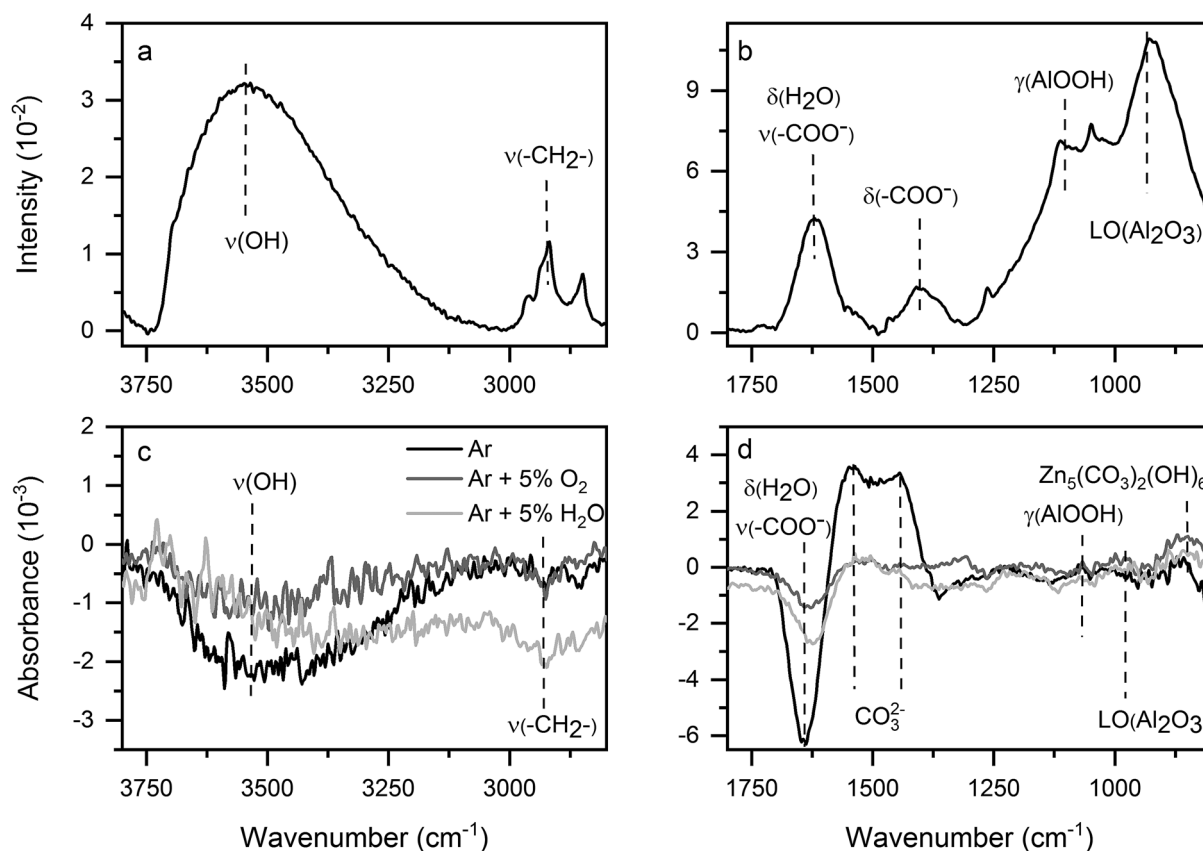


Fig. 3 (a and b) PM-IRRAS of untreated ZnMgAl in two spectral regions. (c and d) *In situ* DPM-IRRAS of ZnMgAl after 60 s plasma treatment with different gas mixtures with respect to the initial state.

IRRAS measurements that the metal surface is covered by carboxylates containing aliphatic carbon chains.^{22–25} (This assumption is also confirmed by XPS.)

All plasma treatments (Fig. 3c and d) induced the removal of adsorbed aliphatic species, water and carboxylates, identified by the appearance of negative bands at the corresponding band positions. Further, all plasma treatments build up carbonates. Two different (positive) bands were associated to carbonates: a peak at 860 cm⁻¹, corresponding to zinc carbonate in form of

hydrozincite,^{2,26} and a broad band centred around 1500 cm⁻¹, due to un-specified carbonates. Carbonate bands appear typically in a broad spectral region between 1540–1150 cm⁻¹ and the precise band position depends both on the type of substrate^{2,26–28} and on the binding mechanism.^{27–29} The two observed carbonate signals appear after all plasma treatments, independently of the gas mixture used. Additionally, the increase of the carbonate peaks was correlated to the decrease in the carboxylate band, suggesting that the plasma treatments

Table 1 Summary of the peaks observed by means of PM-IRRAS and DPM-IRRAS before and after the plasma treatments

Peak position (cm⁻¹)				
Solvent cleaned	Ar plasma	Ar/O₂ plasma	Ar/H₂O plasma	Peak assignment
	860	855	860	Zn₅(CO₃)₂(OH)₆ ^{2,26}
920	—	940	940	LO(Al₂O₃) ³⁰
1020	1020	1020	1020	δ(OCH) ²⁹
1090	1070	1070	1070	γ(AlOOH) ^{30,31}
	1150–1320	1150–1320	1150–1320	Absorbed CO₃ ²⁻
1440	1440	1450	1450	δ(CO₂⁻) from both carbonates and carboxylates ^{27,28,31}
1465				δ(CH₂) ³¹
1540	1535	1520	1510	Absorbed CO₃ ²⁻
1620	1630	1630	1625	ν(CO₂⁻) from carboxylates, ^{28,32} δ(H₂O) ³⁰
2850–2960	2850–2960	2850–2960	2850–2960	νₛ(CH₂), νₛ(CH₃), νₐ(CH₂), νₐ(CH₃) ²⁸
3500–3200	3500–3200	3500–3200	3500–3200	ν(OH) ³⁰



converted carboxylates to carbonates. Contact with the plasma therefore seemed to induce a carbonate conversion that affected both the adsorbed “adventitious” carbonates and the metal carbonates incorporated into the oxide layer. Additional modifications to the oxide layer, dependent on the specific gas mixture, can be seen in the changes in the AlOOH and Al_2O_3 bands.

By evaluating at least eight samples per plasma gas mixture, specific changes in surface chemistry after the plasma treatment could be associated unequivocally to the respective plasma gas mixture. The gas mixture mainly determined the conversion of carboxylates and carbonates in terms of the peak intensities as well as the peak positions associated to carbonates in the region between 1540 and 1150 cm^{-1} . The highest carbonate build-up was observed for the case of pure Ar plasma.

To sum up, DPM-IRRAS measurements showed the decrease in aliphatic carbon and absorbed water and the conversion of carboxylates to carbonates as a results of the of the plasma treatment. The conversion degree was seen to depend on the plasma gas mixture.

3.3 *Ex situ* XPS analysis of surface chemical changes after plasma processing

XPS was used for additional *ex situ* chemical characterization of the sample surface before and after the plasma treatments. The average stoichiometry (several samples were characterized for each treatment) is presented in Table 2. The ratio between the metals was calculated by dividing the metal concentration by the Zn-concentration.

All investigated samples showed only the presence of Al, Mg and Zn plus oxygen and carbon (Fig. S3†). From the stoichiometric data shown in Table 2, it can be seen that the metal component of the untreated surface is dominated by Al. The high C concentration is due to adventitious carbon, as already reported for similar samples.^{17,18}

As already observed in the IR analysis, XPS characterization showed the removal of surface carbon after all plasma treatments. The C1s core level peaks were fitted into four components (Fig. 4). The component at 284.6 eV is associated to aliphatic carbon species, the component at 285.1 eV to ethers, the component at 288.2 eV to carboxylates and the component at 289.2 eV to carbonates.^{28,33} As can be seen in Fig. 4, the plasma treatments led to a distinct increase in carbonate species, while all other components decreased in intensity.

In order to compare the absolute amounts of carboxylate and carbonates, the peak percentage corresponding to each peak component was normalized to the total at% of carbon as

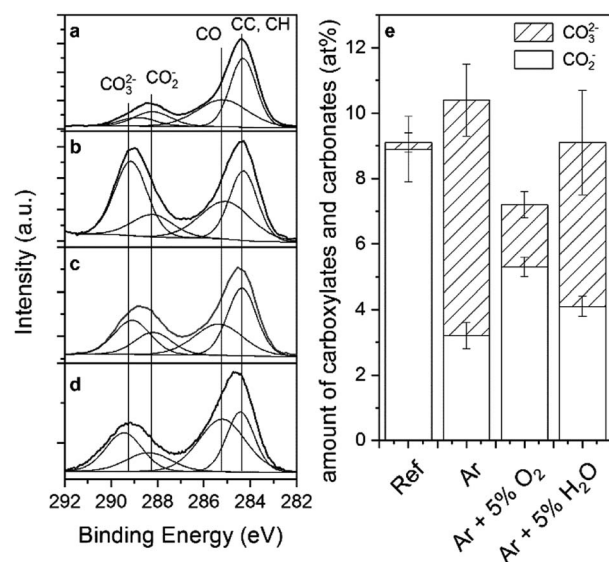


Fig. 4 Element spectra of C 1s before (a) and after the plasma treatment with Ar (b), Ar/O₂ (c) and Ar/H₂O (d). Quantification of carboxylates and carbonates determined by XPS before and after the plasma treatments (e).

determined by XPS (Fig. 4e). Interestingly, the sum of carboxylates and carbonates remained nearly constant during the plasma process and only the ratio of carbonates to carboxylates changed. Thus, the conversion from carboxylates to carbonates implied by the IR analysis was confirmed by XPS. As already seen in the IR spectra, XPS also confirmed that plasma treatments with pure Ar resulted in the highest carbonate formation, and Ar/O₂ the smallest.

Interestingly, the different plasma treatments influenced as well the metal ratios at the near-surface region. In all cases, the Al concentration decreased. Pure Ar plasma led to a strong increase in Mg, while Ar/H₂O plasma mainly caused a surface enrichment of Zn. Changes in surface composition after exposure to low pressure plasmas have already been reported before,^{9,10} and the compositional changes were assigned to a field-induced oxide growth followed by migration. Note that changes in surface composition due to preferential sputtering of the substrate can be excluded due to the small fraction of energetic ions expected to reach the sample surface owing to the high collision rate in the gas phase in an atmospheric-pressure plasma.^{34,35}

In the untreated samples, the core level peaks of Mg 1s showed a fully oxidized Mg component while in the case of

Table 2 Quantitative XPS analysis of ZnMgAl before and after the respective plasma treatments

Substrate treatment	Zn 2p _{3/2} [at%]	Mg 1s [at%]	Al 2p [at%]	O 1s [at%]	C 1s [at%]	Zn : Mg : Al
Reference (solvent cleaned)	0.9 ± 0.3	2.2 ± 0.4	12.3 ± 1.8	41.3 ± 2.8	43.3 ± 2.7	1 : 2.7 : 16.3
Ar	1.6 ± 0.4	5.3 ± 0.2	15.7 ± 0.7	58.1 ± 1.0	19.3 ± 3.5	1 : 3.5 : 10.6
Ar + 5% O ₂	2.0 ± 0.6	4.1 ± 0.2	15.6 ± 2.3	54.2 ± 2.3	24.3 ± 2.2	1 : 2.2 : 8
Ar + 5% H ₂ O	3.5 ± 0.3	4.6 ± 0.6	10.6 ± 0.7	54.7 ± 1.1	26.8 ± 1.3	1 : 1.3 : 3



the Al 2p and Zn 2p peaks, weak components associated to metallic Zn and Al were seen (Fig. S4†). The oxidation and hydroxylation of aluminium due to the plasma treatment could be seen by DPM-IRRAS. This effect is consistent with the XPS characterization, since the metallic component of the Al 2p peak was seen to decrease (the same effect was observed in the Zn 2p core level peak). However, it was not possible to distinguish between metal oxides, hydroxides and carbonates, neither in the core level peaks nor by evaluation of the Auger parameters.^{36,37}

In order to further investigate the oxidation of the metals, the top oxide layer thickness was estimated following Strohmeyer, assuming separated oxide phases (constants used for the calculation shown in Table S2†).³⁸ Please note that this is just a rough estimation, since the actual oxide layer at the surface is inhomogeneous, both in composition and in structure. The results are presented in Fig. 5.

Ar plasma treatment exhibited a certain increase in the thickness of the oxide layer for both Zn and Al; the addition of oxygen containing species led to an enhancement of this effect. Thus, as expected, the generation of oxidizing species seems to be the determining factor for the increase in the oxide layer thickness, although why an Ar plasma treatment would induce the oxidation of the surface is not fully understood. In pure Ar plasma, the presence of OH species was determined by OES and they might be causing the surface oxidation in this case. Adding O₂ to Ar increased the oxide layer thickness slightly, while the addition of H₂O led to a significant enhancement of the oxidizing properties. Thus, water seems to have a higher oxidizing effect than oxygen in this case.

To summarize, XPS confirmed the removal of surface contamination (aliphatic carbon chains) and the conversion of carboxylates to carbonates. Additionally, XPS showed the migration of Zn and Mg towards the surface and an increase in the oxide layer thickness.

3.4 TOF-SIMS imaging and depth profiling

After XPS showed that the metal ratios changed at the near-surface sample region, TOF-SIMS was used to investigate the

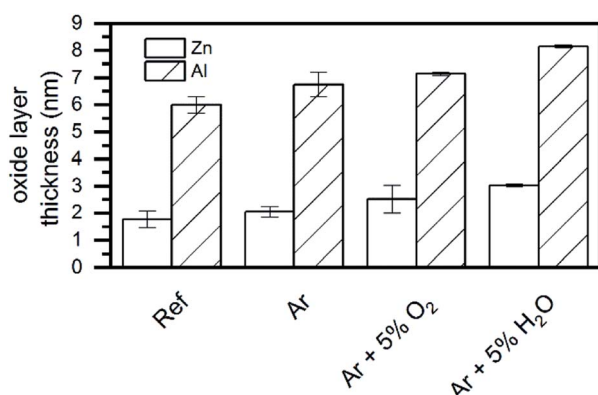


Fig. 5 Calculated oxide layer thickness on ZnMgAl based on the evaluated Zn 2p and Al 2p before and after plasma treatments.

lateral and in-depth redistribution of elements as a result of the plasma treatments.

In ToF-SIMS, secondary ion intensities generally depend on both the specific secondary ion of interest and the matrix.³⁹ If matrix effects can be neglected, intensities of a given secondary ion (such as Zn⁺, Mg⁺ or Al⁺ in this case) could be directly compared between different materials. However, the ZnMgAl coating shows an inhomogeneous structure at the micro- and nanoscale, so that matrix effects cannot be excluded in this case. Thus, the intensities can only be compared between the ZnMgAl samples. Moreover, oxygen, *e.g.* as present in surface oxide layers, is known to increase the signal intensity of metal secondary ions by several orders of magnitude.³⁹ These general complications have to be kept in mind when discussing and interpreting the TOF-SIMS data.

The depth profiles of the major secondary metal ions, Zn⁺, Mg⁺ and Al⁺, are presented in Fig. 6. The curves of Mg⁺ and Al⁺ secondary ions showed similar behaviour with depth: an initial increase of the signal, followed by a maximum and progressive decrease. This trend is similar to the signals of the corresponding metal oxide cluster signals, *i.e.* MgO⁺ and AlO⁺ (see ESI, Fig. S6†). Hence, in a first approximation, it could be said that the profiles show the distribution of the superficial oxide layer. After all plasma treatments, a shift of the intensity maximum towards the bulk was observed, indicating the growth of the oxide layer.

Interestingly, the Zn⁺ secondary ions showed a somewhat different depth profile than Mg⁺ and Al⁺. In the untreated

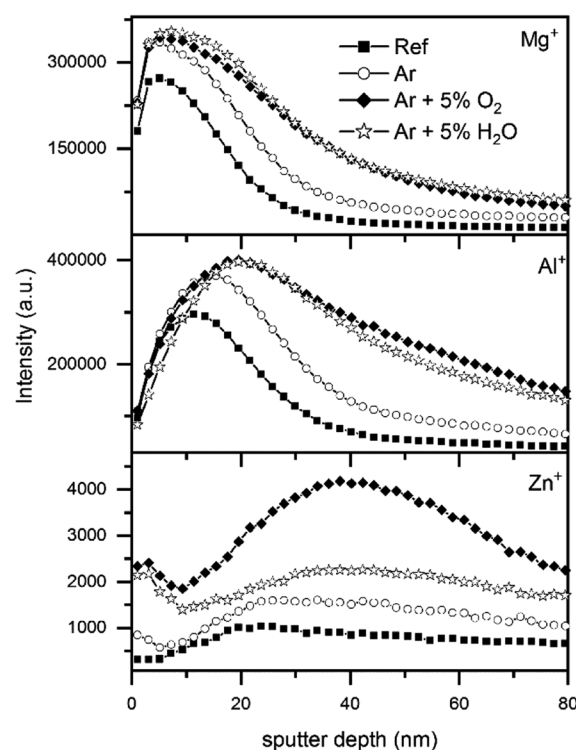


Fig. 6 TOF-SIMS depth profiles of the secondary metal ions Mg⁺, Al⁺ and Zn⁺ for untreated samples and samples with plasma treatments using different gas mixtures.



sample, the Zn^+ signal at the surface was low and increased with increasing depth, reaching a steady state for depths below 20 nm. This curve is consistent with the reported accumulation of Al and Mg on the surface of ZnMgAl. After all plasma treatments, Zn was enriched at the outermost surface as already seen by XPS. Note however, that the Zn^+ signal of the plasma-treated ZnMgAl samples did not reach a steady state with increasing depth as in the case of the untreated sample: after an initial decrease with depth (around 5 nm), the signal increased again, reaching a maximum between 20 and 60 nm depth before decreasing once more.

The TOF-SIMS analysis of the first 10 nm (Fig. S7†) showed that the top oxide layer, both before and after the plasma treatments was homogeneous over surface areas of up to 400 μm , independently of the structures underneath and consisted of Al and Mg.

Therefore, TOF-SIMS could confirm the growth in the oxide layer thickness seen by XPS and additionally revealed plasma induced changes in a depth of several nm. The homogeneity of the top oxide layer over large areas is not affected by the plasma.

3.5 Kelvin probe studies of average surface potentials after plasma processing

Kelvin probe measurements were performed *in situ* to follow the plasma-induced changes in the surface potential, which include changes to the adsorbate layer, metal state and semi-conducting properties. By measuring KP it is possible to evaluate the Galvani potential, which describes the potential necessary to remove from the surface a Fermi-level electron. The Galvani potential difference ($\Delta\phi_{\text{Ref}}^{\text{Me}}$) measured by the KP between the underlying metal and the Kelvin probe is determined by the sum of all potential differences of all interfaces according to formula (4):⁴⁰

$$\Delta\phi_{\text{Ref}}^{\text{Me}} = \Delta\phi_{\text{ox}}^{\text{Me}} + \Delta\phi_{\text{ox}} + \chi_{\text{ox}} + \Delta\psi_{\text{Ref}}^{\text{ox}} - \chi_{\text{Ref}} \quad (4)$$

where $\Delta\phi_{\text{ox}}^{\text{Me}}$ is the potential difference between the oxide and the metal. $\Delta\phi_{\text{ox}}$ describes the potential drop across the oxide layer and is determined by such factors as chemical composition, oxide thickness and conductivity of the oxide layer.^{22,40,41} χ_{ox} is the surface potential of the oxide and is determined by the adsorbed layer on the oxide. Thereby, dipoles formed on the oxide surface play a great role as well as the intrinsic dipole moment of the adsorbed layer.^{22,23} $\Delta\psi_{\text{Ref}}^{\text{ox}}$ and χ_{Ref} are the Volta potential and the surface potential of the probe respectively and are constant values.

KP measurements of at least eight samples were averaged for each plasma gas mixture and the results are shown in Fig. 7.

In all cases, a positive shift of the potential was seen after the plasma treatments. According to the IR and XPS characterizations, the chemical changes induced by the plasma treatments can be summarized as follows: (i) removal of adventitious carbon, (ii) conversion of carboxylates to carbonates, (iii) migration of Mg and Zn towards the surface and (iv) increased thickness of the upper oxide layer. The influence of the four effects in the surface potential are discussed in the following.

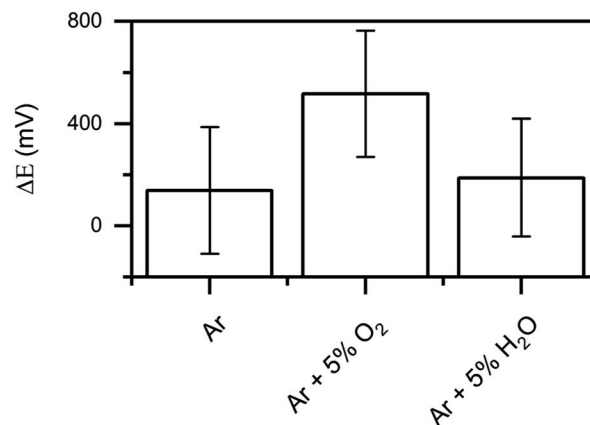


Fig. 7 Differences in the surface potential before and after the respective plasma treatment measured *in situ* with the KP on ZnMgAl. The error bars are the statistic of at least 8 samples per plasma gas mixture.

(i) When adsorbed adventitious carbon and water are removed from the surface, the distribution of surface dipoles changes, with the corresponding effect on the surface potential (χ_{ox}). Taheri *et al.* investigated adsorbed layer on Zn-surfaces and showed that adsorption of contamination on the surface shifted the potential to more positive values.²² Thus, the removal of surface contaminations should result in a negative shift in the surface potential.

(ii) Adsorbed carboxylates form a strong dipole at the surface and therefore strongly influence the surface potential (χ_{ox}).^{22,23} At the same time, the intrinsic dipole moment of carboxylates attached with an aliphatic tail orientated away from the surface is zero and does not contribute to the overall potential drop in the adsorbate layer.^{22,23} Changes in the structure of the carboxylates lead to a change in the intrinsic dipole moment different than zero and therefore change the overall potential. Consequently, the conversion from carboxylates to carbonates influences the dipole moment at the surface as well as the intrinsic dipole moment of the adsorbate layer.

(iii) The migration of the metals can influence the potential difference between the metal and the oxide ($\Delta\phi_{\text{ox}}^{\text{Me}}$) when new boundaries are formed. Due to the complex structure of the oxide/metal interface, the influence of the migration cannot be assessed.

(iv) A growth in the oxide layer thickness leads to a positive shift of the potential drop over the oxide layer ($\Delta\phi_{\text{ox}}$).^{40,41}

The overall positive shift of the potential after the plasma treatments is therefore a combination of the positive shift induced by the oxide layer growth and the changes in the dipole distribution of the adsorbate layer.

3.6 SKPFM imaging of surface potentials

Ex situ characterization of the samples by scanning Kelvin probe force microscopy (SKPFM) was performed before and after the plasma treatments to evaluate the surface roughness and the 2D distribution of the surface potential.



The SKPFM mappings (Fig. 8a–d) revealed a structure similar to FE-SEM and TOF-SIMS measurements, both in topography and surface potential. Fig. 8a and b show the situation corresponding to the untreated sample. Previous characterization of such alloys, such as the one done by Lostak *et al.* showed that the surface potential depends on the local bulk composition for ZnMgAl alloys.¹⁷ Indeed, given the clear compositional inhomogeneity of the sample, one would expect potential variations corresponding to the individual standard potentials of the separated phases. The mapping shown in Fig. 8b, however, shows relatively small standard potential variations. This is most probably due to the muffling effect of the thin top oxide layer, whose homogeneity over large areas of the sample was determined by the ToF-SIMS measurements presented before. After plasma treatment, the variations in surface potential along the surface area are even smaller. To evaluate the changes, the R_q value for the height maps (roughness) and for the potential maps (potential range) were calculated (Fig. 8e and f). All samples exhibited high roughness (300 nm on a $70 \times 70 \mu\text{m}^2$ scale), which was not affected by the plasma treatments. However, as already mentioned, the surface potential showed a distinct homogenisation after the plasma treatment with Ar/O₂ and Ar/H₂O. The potential homogenisation correlates with the increase of the oxide layer thicknesses determined by XPS and TOF-SIMS. With increasing oxide layer thickness, the influence of the bulk material (in-homogeneously distributed) on the surface is reduced, thus leading to a more homogenous surface potential. Additionally, the conversion of carboxylates to carbonates on the surface, with the corresponding redistribution of surface dipoles, might also affect the surface potential.

3.7 Water contact angle studies

Water contact angles were measured to investigate the change in the wettability of the surface after the plasma treatments. The results are shown in Fig. 9.

The untreated surface showed a high contact angle of 70°. This is explained by the presence of the native carboxylate adsorption layer. This leads to an un-polar surface due to the presence of aliphatic carbon chains. As already discussed, one of the main results of the plasma treatments is the removal of these aliphatic chains, which should result in an increase of surface wettability. As expected, the contact angle was reduced to around 20° in all cases after the plasma treatment. The Ar/O₂ plasma, which showed the lowest removal rate of aliphatic carbon, was thus resulting in the highest contact angle.

3.8 Peel test studies for the analysis of surface adhesive properties

Peel test was used to investigate the influence of the plasma treatments on the adhesion strength for an acrylate adhesive tape and an epoxy amine adhesive. The results are presented in Fig. 10.

The peel forces measured for the epoxide amine adhesive on the untreated surface were in the same range as reported in the literature.^{42,43} The acrylate showed a higher peel force than the epoxide amine adhesive. The adsorption of polyacrylic acid molecules to metal oxides such as Al₂O₃ and ZnO has been deeply studied by several authors.^{44,45} We assume that the reason for the increased adhesion forces in the case of acrylate based adhesive is that carboxylic groups form strong acid–base interactions with the surface metal ions due bidentate bindings.

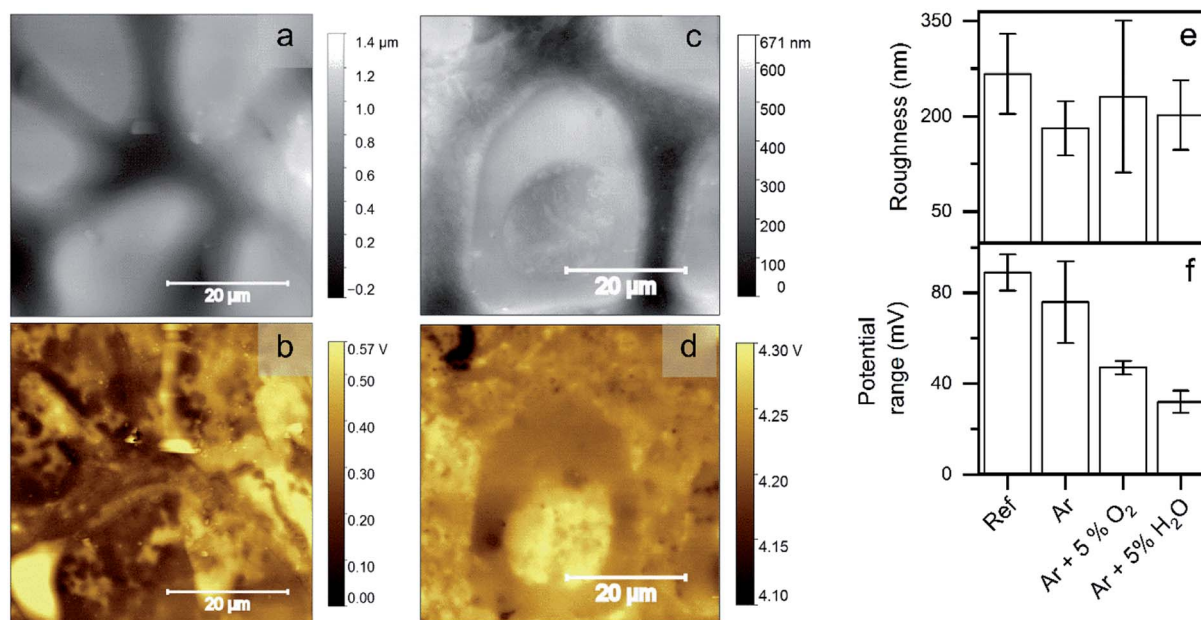


Fig. 8 SKPFM mappings of an untreated ZnMgAl alloy ((a) topography and (b) surface potential) compared to a sample plasma treated with Ar/H₂O ((c) topography and (d) surface potential). (e) Evaluation of the roughness and (f) the surface potential range before and after the respective plasma treatment.



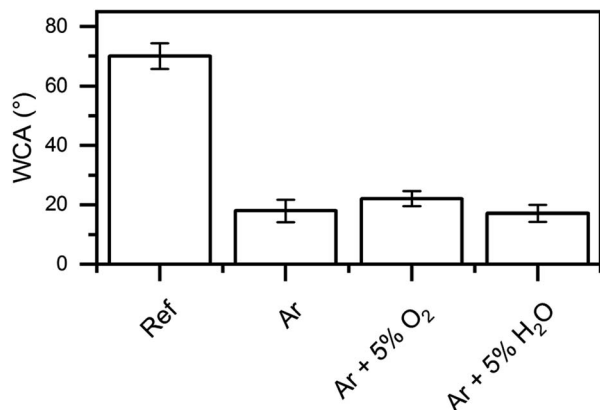


Fig. 9 Water contact angle measurements before and after the plasma treatments.

By comparison, the amine and alcohol functions of the epoxy amine adhesive form interfacial monodentate bonds.

The peel force was increased by all plasma treatments for both adhesives. Plasma treatments with Ar and Ar/O₂ showed only small increases in the peel force, while plasma treatments with Ar/H₂O led to a significant increase for both adhesives. The increase was particularly distinctive in the case of the epoxy amine adhesive, where the peel force was improved by a factor of 3. This increase in the peel force is in the range of improvements introduced by commonly used adhesion promotion layers such as γ -APS.⁴³

As already discussed, the surface of untreated ZnMgAl is made of an oxyhydroxide surface, covered by a layer of adsorbed carboxylates and aliphatic carbon groups. When an adhesive is applied to this surface, the acid–base interaction of the polar groups of the adhesive with the metal surface is hindered by the presence of the aliphatic carbon groups, which are not polar in nature. The plasma treatments etch the aliphatic carbon groups and convert carboxylates to carbonates. The conversion to carbonates (polar) combined with the loss of the aliphatic carbon groups leads to a better interaction of the adhesive with the surface.

Nevertheless, plasma treatments with small carbonate conversion, such as the Ar/O₂ plasma, show a significant increase in adhesion between adhesive and surface as well. That

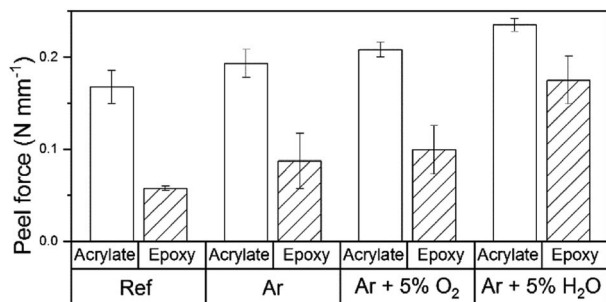


Fig. 10 Peel test results before and after the plasma treatment for acrylate coated tape and epoxy amine adhesive.

suggests that additional mechanisms might need to be taken into account. While pure Ar plasma mainly created carbonates combined with the etching of aliphatic carbon groups, Ar/O₂ plasma primarily induced an increase in the oxide layer thickness followed by a homogenisation of the surface potential. Both processes led to a similar increase in the peel force independent of the adhesive. It is important to note that plasma treatments with Ar/H₂O, which induce all the discussed effects in a high degree, showed the highest performance with both adhesives, thus showing the synergistically nature of the plasma-induced changes on the adhesion. How this combination of factors in detail affects the overall adhesive properties of the surface is not clear at present.

4. Conclusions

A combination of the surface characterization techniques DPM-IRRAS, XPS, KP, TOF-SIMS and SKPFM allowed the identification of five different plasma-induced surface effects in the DBD plasma treatment of ZnMgAl alloys. The effects are: surface conversion of carboxylates to carbonates, etching of aliphatic carbon groups, migration of metals, increased top oxide layer, and homogenization of the surface potential. These changes appear in greater or lesser degree depending on the gas mixture. Although an improvement of adhesion properties and wettability was observed after all plasma treatments, there was not a clear correlation between a specific surface effect and the improved adhesion behaviour. Ar plasma, which mostly produced the etching of aliphatic chains and conversion of carboxylates to carbonates of the surface, showed a similar improvement in adhesion as the Ar/O₂ plasma, where the main effect was the increased oxide layer and homogenization of surface potential. Interestingly, treatment with the Ar/H₂O plasma, which induced all discussed effects in high degree, resulted in the highest adhesive improvement, suggesting that all effects synergistically contribute to the final improvement. The improved adhesion after removal of aliphatic carbon chains and the conversion of carboxylates to carbonates of the surface can be partly explained by the formation of polar groups at the surface that can interact with the polar groups of the adhesive. However, it is not fully understood at present how the combination of all observed factors collectively affect the adhesion.

Conflicts of interest

There are no conflicts to declare.

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